

PATENT Attv. Ref. P97.0027

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANTS:

Hiroshi Tavanaka

SERIAL NO .:

08/818.239

GROUP ART UNIT: 2813

FILED:

March 14, 1997

EXAMINER: K. Christianson

FOR:

"METHOD FOR MAKING THIN FILM SEMICONDUCTOR,

SOLAR CELL, AND LIGHT EMITTING DIODE"

Assistant Commissioner for Patents Washington, D.C. 20231

AMENDMENT

TECHNOLOGY CENTER 2800

Dear Sir:

In response to the Office Action mailed December 3, 1998, kindly amend the above-identified application as follows:

IN THE SPECIFICATION:

At page 21, line 2, please delete "Si1-yGey" and insert --Si<sub>1-y</sub> and Ge<sub>y</sub>--.

At page 29, lines 6-7, please delete "around here" and insert -- at this location--.

At page 33/line 3/please delete "around here" and insert --at this location--.

At page 40 line 3, please delete "mA/cm2" and insert --mA/cm2--.

At page 45, line 20, after "atoms/cm3" please delete "," and insert --.--.

IN THE CLAIMS:

Kindly amend Claims 5 and 6 in accordance with 37 CFR 1.121(b) as follows:

5. (Amended) A method as defined in Claim 3, wherein in the anodizing